

高解析實境顯示基礎原理

Basic principles of high-resolution reality displays

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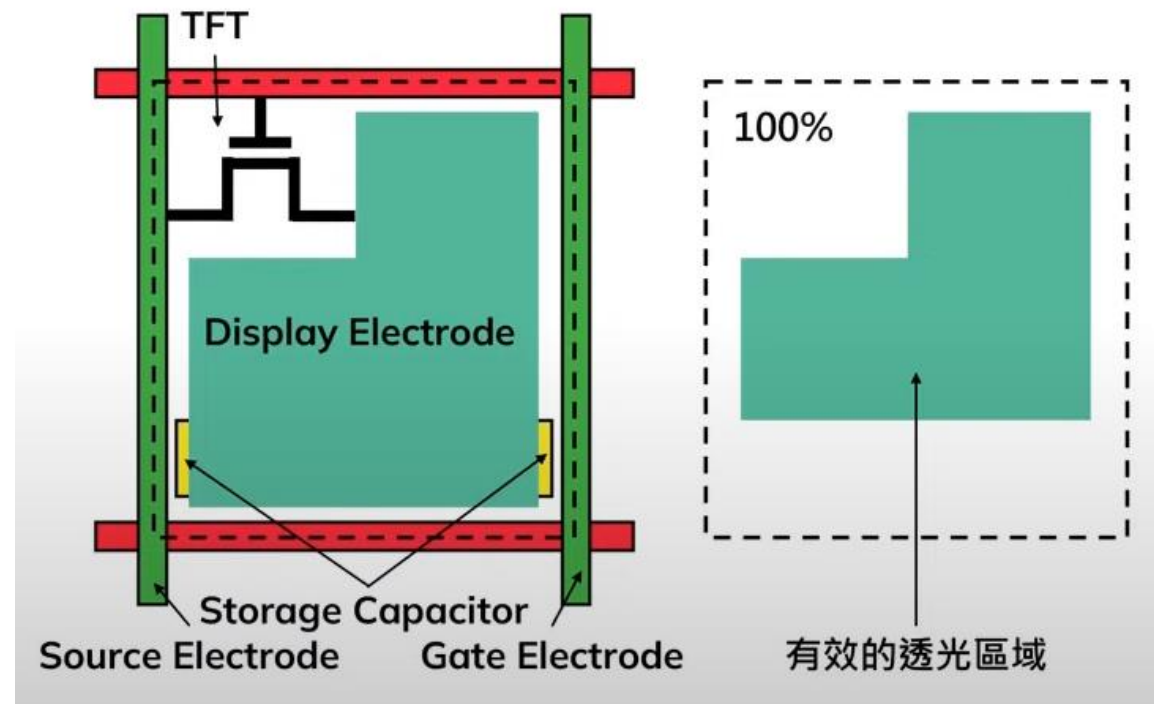


Chapter 5: 高解析度液晶顯示的難點



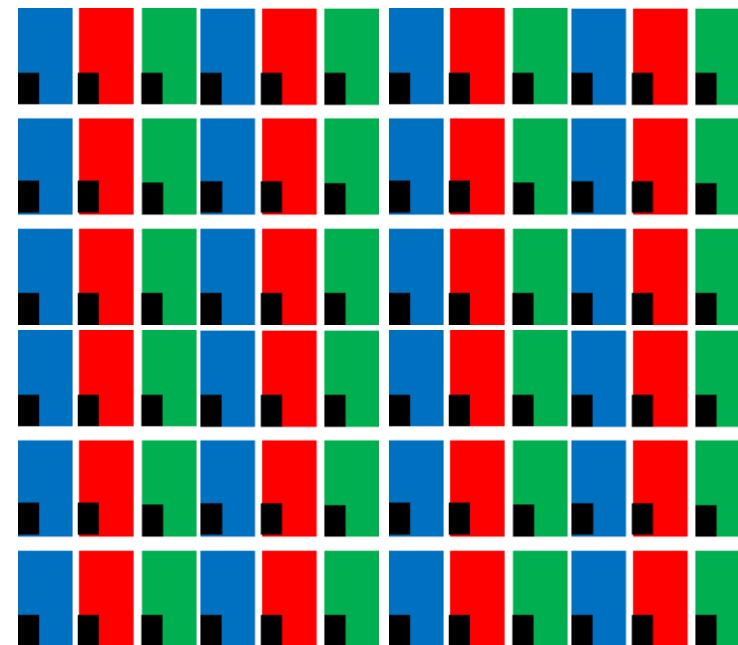
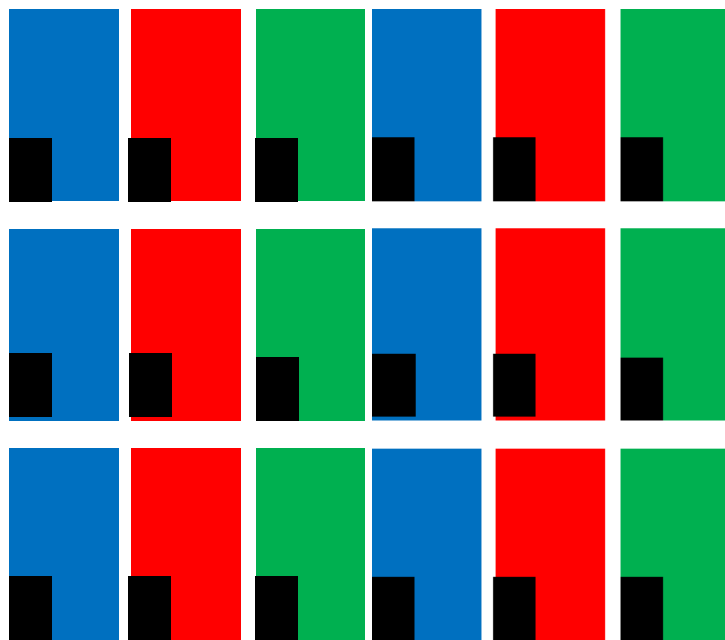
開口率

$$\text{開口率} = \frac{\text{透光區面積}}{\text{像素面積}} \times 100\%$$

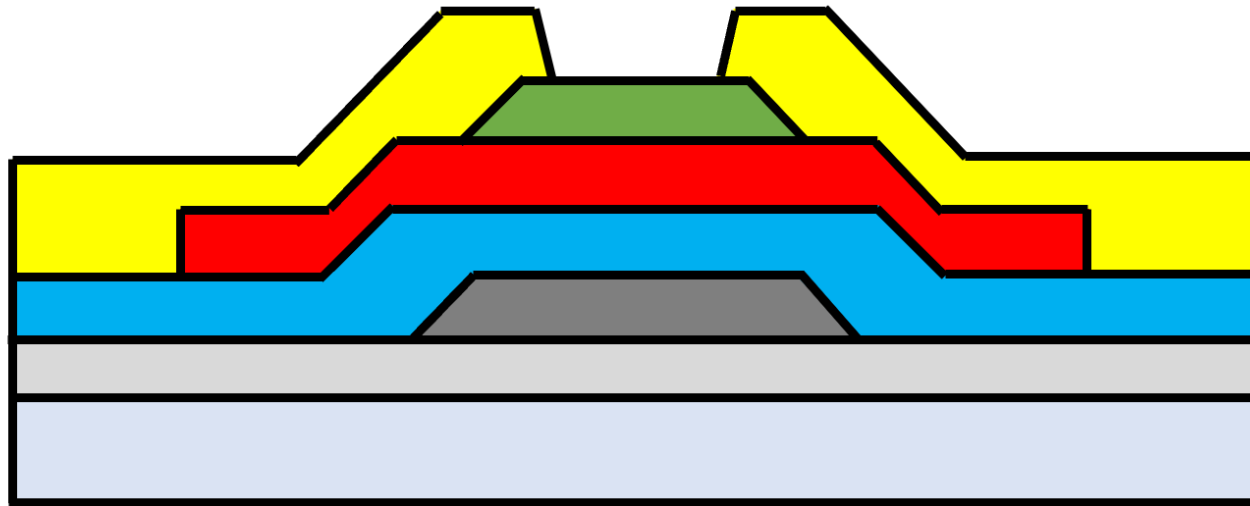









解析度上升帶來的問題

1. 開口率下降
2. 耗電量上升



薄膜電晶體(Thin-Film Transistor)



- | | | |
|--|---|---|
|  Glass |  Buffer Layer |  Gate Metal |
|  Dielectric |  Metal Oxide Semiconductor | |
|  Etch Stop |  Source / Drain Metals | |

$$I_D = \frac{1}{2} \mu_n C_{ox} \frac{W}{L} (V_{GS} - V_{th})^2$$



載子遷移率

電子運動速度等於遷移率乘以電場強度，也就是說相同的電場強度下，載子遷移率越大，運動得越快；遷移率小，運動得慢。同一種半導體材料中，載子類型不同，遷移率不同。

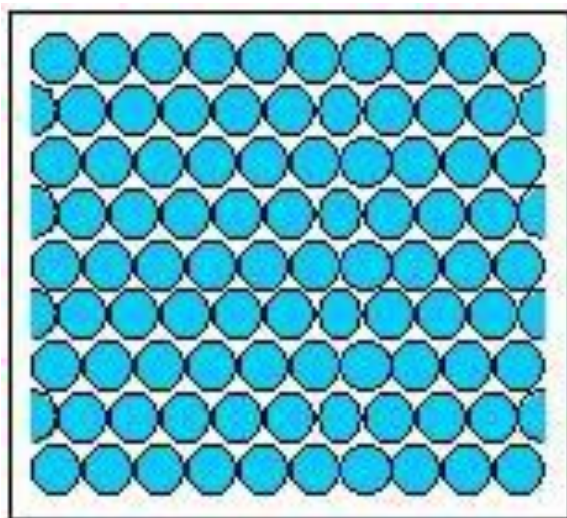
遷移率主要的影響：

1. 電導率
2. 工作頻率



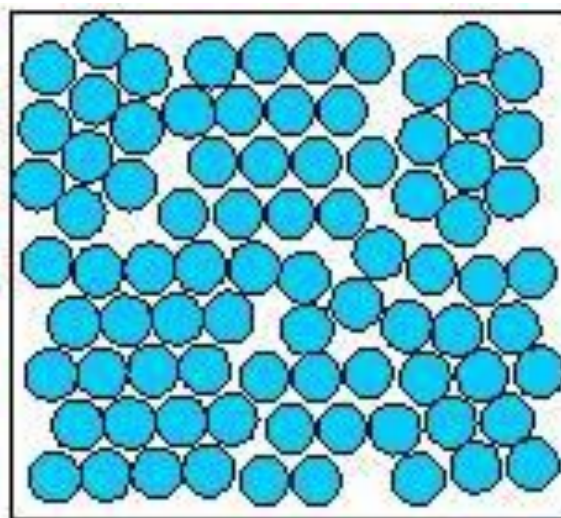
薄膜電晶體材料

材料縮減→需要更高載子遷移率的材料



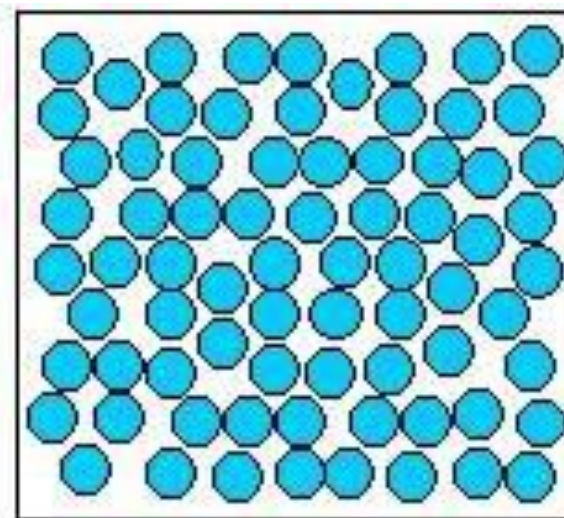
Single crystal
Periodic across the
whole volume.

單晶



Polycrystal
Periodic across
each grain.

多晶

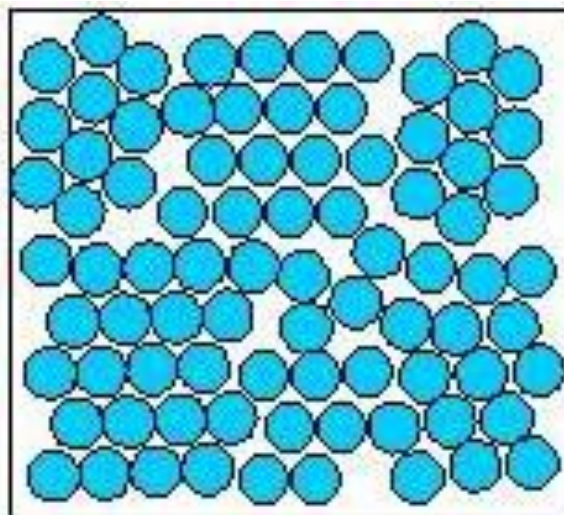


Amorphous solid
Not periodic.

非晶



薄膜電晶體材料



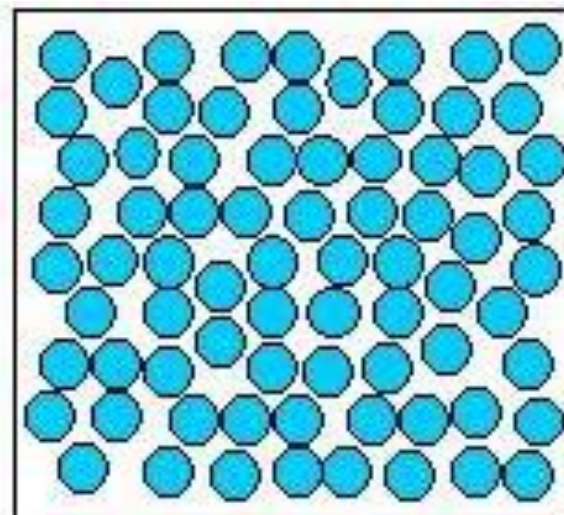
Polycrystal

Periodic across
each grain.

載子遷移率:

$100 \text{ cm}^2 \text{ V}^{-1} \text{ s}^{-1}$

像素密度 > 300 PPI



Amorphous solid

Not periodic.

載子遷移率:

$0.5 \sim 1 \text{ cm}^2 \text{ V}^{-1} \text{ s}^{-1}$

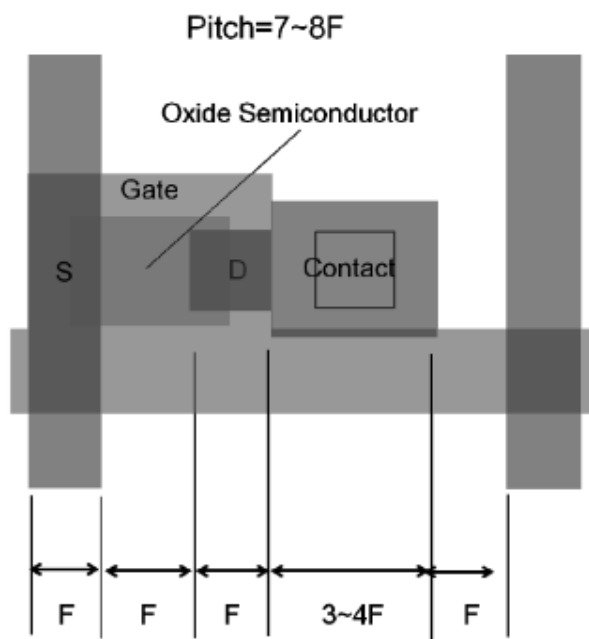
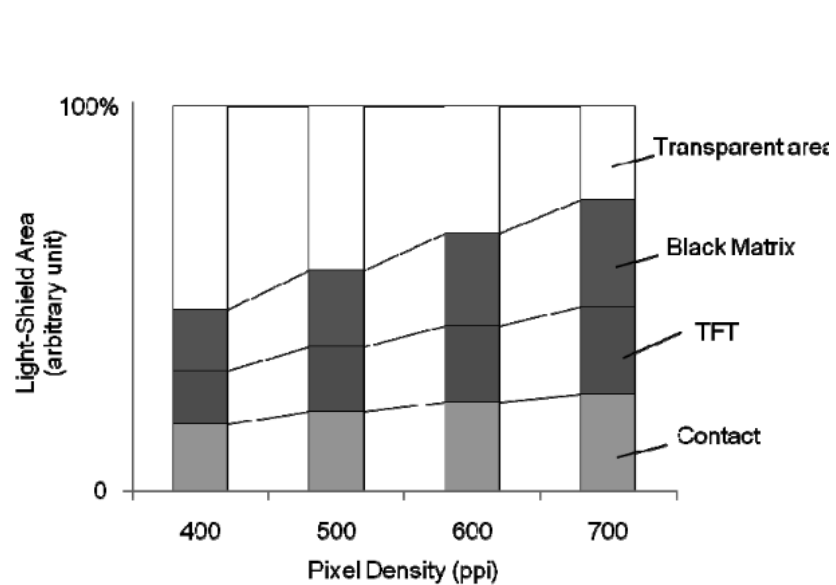
像素密度: 200~300 PPI



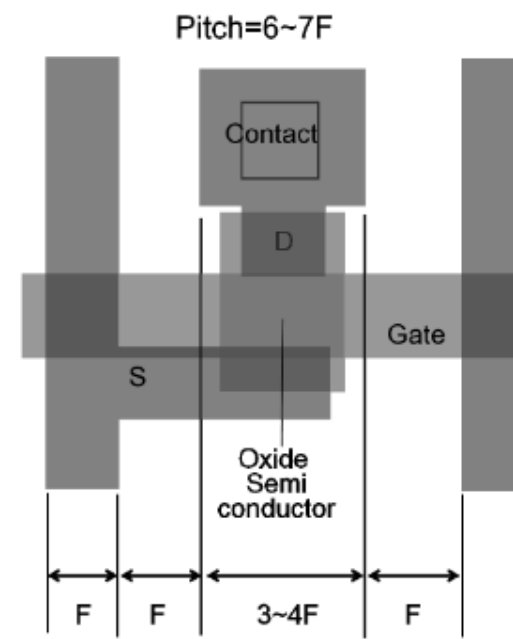
薄膜電晶體材料

Sharp Corporation

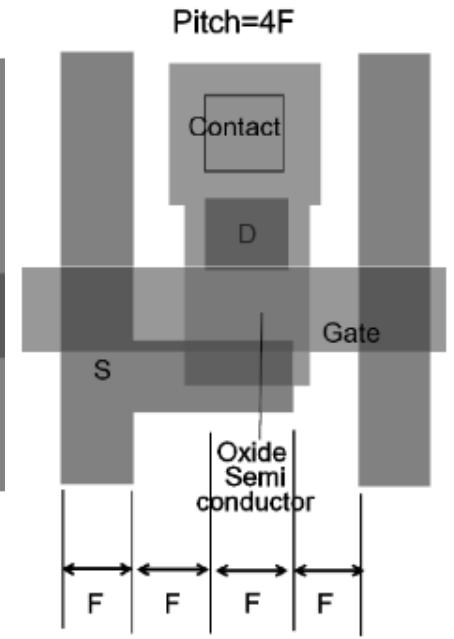
An Ultra High Density 736-ppi Liquid Crystal Display using InGaZnO Platform-SID 2018



(A)



(B)



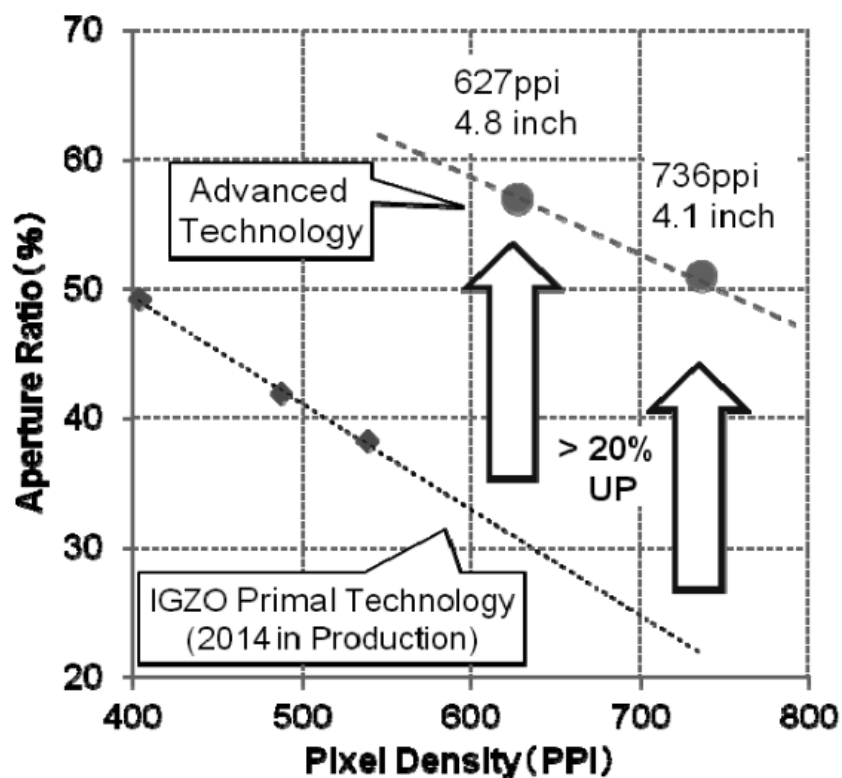
(C)



薄膜電晶體材料

Sharp Corporation

An Ultra High Density 736-ppi Liquid Crystal Display using InGaZnO Platform-SID 2018



Panel Size	4.10 inch	4.80 inch
Resolution No. of pixels	WQXGA 2560 x 1600	
Resolution	736ppi	627ppi
Pitch size	11.5μm x RGB x 34.5μm	13.5μm x RGB x 40.5μm
Design Rule	LTPS mass-production equivalent	
TFT size (Channel W / L)	3um / 3.5um X 1	
Aperture Ratio	51%	57%
Bezel Width	—	0.9mm



Thank you for your attention

